

## IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF:

OTOJIRO KIDA ET AL.

**GROUP ART UNIT: 1753** 

SERIAL NO.: 09/729,102

FILED: December 5, 2000

EXAMINER: VERSTEEG

FOR:

TARGET AND PROCESS FOR ITS

PRODUCTION, AND METHOD FOR

FORMING A FILM HAVING A HIGHLY REFRACTIVE INDEX

## **DECLARATION**

ASSISTANT COMMISSIONER FOR PATENTS WASHINGTON, D.C. 20231

SIR:

Now comes MASAYUKI KUWANO who deposes and says:

That my name is MASAYUKI KUWANO;

That my address is 5-24-310, 3-chome, Nakamachi,

Musashino-shi, Tokyo, Japan;

That I know well both the English and Japanese languages;

That the attached English language translation is true and correct translation of Japanese Patent Application No. 7-215074 filed on August 23, 1995 to the best of my knowledge and belief;

I hereby declare further that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of this application or any patent issuing thereon.

FURTHER DEPONENT SAITH NOT.

Date

MASAYIIKI KIIWANO